SYNTHESIS AND CHARACTERIZATION OF ULTRALONG Si3N4 NANOBELTS WITH UNIQUE OPTICAL AND FLEXIBLE NANOMECHANICAL PROPERTIES

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ABSTRACT

In this paper, several millimeters long Si3N4 nanobelts (NBs) with a cross-section of 100-700 nm in width and 30-200 nm in thickness were successfully synthesized via an effective method with the raw materials of graphite, nanosilicon and nanosilica. Alumina-assisted vapor-liquid-solid (VLS) was proposed for the growth mode of ultra-long Si3N4 NBs, in which alumina may be as a novel and highly effective mediator playing an important role in adjusting the content of reactive silicon during the growth of ultra-long Si3N4 NBs. The room-temperature photoluminescence (PL) spectrum showed that the synthesized α-Si3N4 NBs had two strong emissions peaks centered at 551 nm (2.25 eV) and 697 nm (1.78 eV) located in the yellow and red spectral range, which can be explained by the size effect and presence of a small amount of Al, offering an effective method for preparing Si3N4 nanomaterials with unique optical properties. In situ nanoindentation was used to probe the nanomechanical property of Si3N4 NBs by a hybrid SEM/SPM system and the Young’s modulus of a Si3N4 NB with about 300 nm in width and 100 nm in thickness was approximately 483.78 GPa, suggesting much larger than those of bulk and film of the Si3N4 materials, providing value and guidance for studying the properties of Si3N4 nanomaterials and for expanding their possible applications.⁵

1 INTRODUCTION

Owing to their unique and excellent properties compared with their bulk counterparts, one-dimensional (1D) silicon nitride (Si3N4) nanomaterials (e.g., nanowires and nanobelts) have attracted considerable attention due to their potential applications in widely fields with composites, nano- and micro- electronic, and nanoscale devices.¹ Numerous techniques, including the pyrolysis of polymeric precursors, carbothermal reduction and chemical vapor deposition (CVD), are applied to synthesis 1-D Si3N4 nanomaterials.² Moreover, the lengths on the order of millimeters or even centimeters long Si3N4 nanomaterials might be more valuable compared to short ones in some fields (e.g., connections for devices and reinforcements for composites).³ Inspired by this, some literatures have been reported about the preparation of high-yield and ultra-long Si3N4 nanomaterials according to our survey.⁴ It is worth noting that an accurate measurement of the nanomechanical properties of 1D Si3N4
nanomaterials is of critical importance before they are applied in all of the above applications. Scanning probe microscopy (SPM) has proven to be a valuable device for manipulating and characterizing the properties of individual nanostructures through techniques such as nanoindentation, three-point bending and tensile tests. However, to the best of our knowledge there has not been a report of the nanomechanical properties of Si$_3$N$_4$ nanowires (NWs) by an SPM/SEM system up to now.\textsuperscript{5}

![Figure 1: (a)-(b) SEM images of the as-prepared white wools obtained on the inner wall of ceramic crucible. Inset: the macroscopic morphology of the achieved products. (c) PL spectra of α-Si$_3$N$_4$ NBs obtained on the inner walls of ceramic crucible (red line marked as NBs-C) and on the inner walls of graphite crucible (black line marked as NBs-G) under excitation of a 325 nm He-Cd laser at room temperature. (d) A typical force-displacement curve extracted from nanoindentation experiments with different fitted curves as displacement increases.\textsuperscript{5}]

2 CONCLUSIONS

Ultra-long Si$_3$N$_4$ NBs with several millimeters long were successfully prepared by a low-cost method with simple raw materials. Alumina-assisted VLS mechanism was used to disclose the growth process of Si$_3$N$_4$ NBs obtained on the inner walls of the crucible with a cross-section of 100-700 nm in width and 30-200 nm in thickness, in which alumina might play an important role in the growth of ultra-long Si$_3$N$_4$ NBs. The PL spectrum of α-Si$_3$N$_4$ NBs at room temperature showed two strong emission peaks located at 551 nm (2.25 eV) and 697 nm (1.78 eV), in which a possible emission mechanism was also proposed with a larger size and a small amount of Al. The Young’s modulus of Si$_3$N$_4$ NBs with an average value of 483.78 GPa was comparable to the values reported in the literature suggesting that this method not only provides an effective way to synthesis ultra-long Si$_3$N$_4$ NBs on an industrial scale, but also supplies significance guidance in the studies of the mechanical properties and the applications of Si$_3$N$_4$ nanomaterials.\textsuperscript{5}

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